Development and Application of Condense Phase Cavity Ring Down Spectroscopy

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electrostatic force for DMP+.

INTRODUCTION

There are many theoretical and experimental studies done to inspect the physical and chemical properties of silica surface. The main properties of silica surface are adjusted by the silanol group (SiOH). The average surface density of silanol groups on the surface is ~4.9 nm^{-2} , which corresponds to an average surface area of 20.4Å² per silanol group. In chromatography, the ionization degree of silanol group plays a great role for separation efficiency. From some other reports, these results pointed out that there are at least two types of silanol groups on the silica surface which contacts with water, with different pKa and different population. One has pKa=4.9 with 19% in surface population and another one has pKa=8.5 with 81% in surface population. A study done by Dong, Pappu, and Xu using crystal violet to probe the local density distribution of isolated silanol groups on silica surface had pointed out that the isolated silanol group has been surrounded by a large empty surface area (≥ 120 Å²) and the surface density of this type is about 1.1'10¹³ cm⁻². In this experiment, the silanol group properties has been studied by evanescent wave cavity ring down spectroscopy in which the adsorption process in CH₃CN/ Fused silica interface.

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Basic equations

1. Empty Cavity

$$I(t) = I_0 \exp\left[-(1-R)\frac{tC}{L}\right]$$

$$r : Speed of velocity$$

$$L : Length of cavity$$

$$t_0 = \frac{tr}{2(1-R)}$$
(Ring down time constant)
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2. Analyst Presence

$$I(t) = I_0 \exp\left[-(1-R+\alpha L)\frac{t_C}{L}\right]$$
$$\tau_1 = \frac{t_r}{2(1-R+\alpha L)}$$

3. Absorbance

 $A = \sigma N l_s = \sigma l_s = \frac{L}{c} \left(\frac{1}{\tau_1} - \frac{1}{\tau_0} \right)$

* Langmuir adsorption model :

 $\theta = \frac{N}{N_0} = \frac{KC}{1+KC}$ N: surface density, N_{θ} : saturation surface K: equilibrium constant C: bulk concentration of sample $N = N_{\theta} \bullet \frac{KC}{1 + KC}$ $\frac{1}{\theta} = \frac{1 + KC}{KC} = 1 + \frac{1}{KC}$

$$A_{\mu} \propto a\pi\mu i \left[\left\langle \cos \theta \right\rangle E_{z}^{2} + \frac{1}{2} \left(2 - \left\langle \cos \theta \right\rangle \right) E_{z}^{2} \right]$$
$$A_{\mu} \propto \frac{a\pi\mu i^{2}}{2} \left[\left(2 - \left\langle \cos^{2} \theta \right\rangle \right) E_{\mu}^{2} \right]$$

$$\frac{2}{\left(\cos^{2}\theta\right)} = \frac{2A_{p}E_{y}^{2} - 2A_{s}E_{x}^{2}}{2A_{s}E_{z}^{2} - A_{s}E_{x}^{2} + A_{a}E_{y}^{2}}$$

EXPERIMENT



RESULTS AND DISCUSSION



II. Orientation Information:



Two sites Langmuir adsorption plot for CV⁺ at CH₃CN/fused silica surface:



From the Langmuir plot and angle plot , the conclusion that the adsorption for CV+ on type I silanol groupcould be more free no matter for the distance aspect and orientation aspect could be made. However, the adsorption between CV+ and type II silanol group could be more restrictedly.